What is claimed is:

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- 1. A method for manufacturing an organic light-emitting diode, comprising: providing a substrate into a chamber;
- 5 forming an anode on the substrate;

forming a hole transport layer on the anode, wherein the step of forming the hole transport layer comprises adding a reaction gas, and the reaction gas forms a plurality of impurities to trap holes;

forming an electron transport layer on the hole transport layer; and forming a cathode on the electron transport layer.

- 2. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the substrate is a transparent substrate.
- 3. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the material of the substrate is selected from the group consisting of glass, silicon and plastics.
- 4. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the anode is an indium tin oxide (ITO) transparent electrode.
 - 5. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the anode is an indium zinc oxide (IZO) transparent electrode.
- 25 6. The method for manufacturing an organic light-emitting diode according to

claim 1, wherein the step of forming the anode is performed by using a method selected from the group consisting of a sputtering method, an evaporation method, an e-gun evaporation method, a spin-coating method and a chemical vapor deposition method.

- 7. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the material of the hole transport layer is an organic material having a hole transport function.
- 8. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the material of the hole transport layer comprises N,N'-diphenyl-N,N'-bis(3-methyl-phenyl)-1,1'biphenyl-4,4'diamine (TPD).
- 9. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the material of the electron transport layer is an organic material
 15 having an electron transport function.
 - 10. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the material of the electron transport layer comprises aluminum tris-(8-hydroxyquinoline) [Alq₃].
 - 11. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the material of the cathode is selected from the group consisting of metal and compound metal.
- 25 12. The method for manufacturing an organic light-emitting diode according to

claim 1, wherein the material of the cathode is aluminum.

- 13. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the step of forming the hole transport layer further comprises controlling an initial growth pressure of the hole transport layer between 1×10^{-8} torr and 1×10^{-3} torr.
- 14. The method for manufacturing an organic light-emitting diode according to claim 1, wherein in the step of forming the hole transport layer, further comprises controlling a pressure of the chamber between 1×10⁻⁷ torr and 1×10⁻² torr when adding the reaction gas.
 - 15. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the step of forming the hole transport layer is performed for 100 seconds to 5 minutes.
 - 16. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the reaction gas is selected from the group consisting of N_2 , NH_3 , N_2O , NO and NO_2 .

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- 17. The method for manufacturing an organic light-emitting diode according to claim 1, wherein a flow rate of the reaction gas is between 1 sccm and 20 sccm.
- 18. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the step of forming the electron transport layer further comprises

controlling a growth pressure of the electron transport layer between 1×10^{-8} torr and 1×10^{-3} torr.

- 19. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the step of forming the electron transport layer is performed for 100 seconds to 6 minutes.
- 20. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the step of forming the cathode further comprises controlling a pressure of the chamber between 1×10⁻⁸ torr and 1×10⁻² torr.
 - 21. The method for manufacturing an organic light-emitting diode according to claim 1, wherein the step of forming the cathode is performed for 1 second to 1 minute.
 - 22. A method for manufacturing an organic light-emitting diode, comprising: providing a substrate into a chamber, wherein an anode is formed on the substrate;

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performing an evaporation step to form a hole transport layer on the anode, wherein the evaporation step comprises evaporating the material of the hole transport layer and a reaction gas to make the reaction gas form a plurality of impurities in the hole transport layer to confine holes;

forming an electron transport layer on the hole transport layer; and forming a cathode on the electron transport layer.

23. The method for manufacturing an organic light-emitting diode according to

- claim 22, wherein the substrate is a transparent substrate, and the material of the substrate is selected from the group consisting of glass, silicon and plastics.
- 24. The method for manufacturing an organic light-emitting diode according to
 5 claim 22, wherein the anode is selected from the group consisting of an indium tin oxide transparent electrode and an indium zinc oxide transparent electrode.
 - 25. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the step of forming the anode is performed by using a method selected from the group consisting of a sputtering method, an evaporation method, an e-gun evaporation method, a spin-coating method and a chemical vapor deposition method.

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- 26. The method for manufacturing an organic light-emitting diode according to claim 22, wherein between the step of providing the substrate and the evaporation step, the method for manufacturing an organic light-emitting diode further comprises performing a pump step to make the chamber have an initial growth pressure of the hole transport layer.
- 27. The method for manufacturing an organic light-emitting diode according to claim 26, wherein the initial growth pressure is between 1×10^{-8} torr and 1×10^{-3} torr.
 - 28. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the material of the hole transport layer is an organic material having a hole transport function.

29. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the material of the hole transport layer comprises N,N'-diphenyl-N,N'-bis(3-methyl-phenyl)-1,1'biphenyl-4,4'diamine.

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30. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the material of the electron transport layer is an organic material having an electron transport function.

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31. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the material of the electron transport layer comprises aluminum tris-(8-hydroxyquinoline).

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32. The method for manufacturing an organic light-emitting diode according to claim 22, wherein in the evaporation step, further comprises controlling a pressure of the chamber between 1×10^{-7} torr and 1×10^{-2} torr.

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33. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the evaporation step is performed for 100 seconds to 5 minutes.

34. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the reaction gas is selected from the group consisting of N2, NH3, N₂O, NO and NO₂.

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35. The method for manufacturing an organic light-emitting diode according to

claim 22, wherein a flow rate of the reaction gas is between 1 sccm and 20 sccm.

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- 36. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the step of forming the electron transport layer further comprises controlling a growth pressure of the electron transport layer between 1×10^{-8} torr and 1×10^{-3} torr.
- 37. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the step of forming the electron transport layer is performed for 100 seconds to 6 minutes.
 - 38. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the material of the cathode is selected from the group consisting of metal and compound metal.
 - 39. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the material of the cathode is aluminum.
- 40. The method for manufacturing an organic light-emitting diode according to claim 22, wherein the step of forming the cathode is performed for 1 second to 1 minute.